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NANONEX RECEIVES FIRST EUROPEAN ORDER FOR THE ULTRA-100, A NEW INTEGRATED UV-OZONE CLEANER-MOLECULAR VAPOR COATER UNIT FROM CENTRE NATIONAL DE LA RECHERCHE SCIENTIFIQUE (CNRS-LAAS), TOULOUSE, FRANCE

Princeton, NJ, October 9, 2006: Nanonex Corporation, the leader in nanoimprint solution and applications with the longest history, announces today the first European order received from the Centre National de la Recherche Scientifique (CNRS-LAAS) Toulouse, France, for the newly introduced *Ultra-100*, a desktop-design integrated UV-Ozone cleaner and molecular vapor coater unit.

The *Ultra-100* is designed to be used for nanoimprint mask surface release treatment, wafer surface adhesion promotion, MEMS /NEMS anti-stiction coating, micro and nano fluidic channel surface treatment, all-purpose UV-Ozone cleaning, thin resist stripping, as well as UV curing in vacuum or gas environment. The tool has automatic operation with standard programs or user-set programs.

CNRS-LAAS will use the *Ultra-100*, in part, to support their existing micro-nano fabrication activities.

John Pong, Sales Director at Nanonex said the company is delighted that CNRS-LAAS has selected the *Ultra-100* to improve their fabrication efficiency and capability. It is an important milestone for Nanonex to have started an European *Ultra-100* customer base.

Nanonex has also supplied nanoimprint lithography systems to customers in USA, Asia and Europe; as well as nanoimprint materials (resists and molds) to customers in USA, Canada, UK, France, Germany, Japan, Taiwan, Korea and Singapore.

About Nanonex Corp.

Nanonex, a pioneer and a leader in nanoimprint, provides a complete line of nanoimprint lithography (NIL) technology solutions including tools, resists, masks, and processes. Nanonex NIL solutions offer sub 10 nm feature resolution, 3D patterning, large area uniformity, accurate overlay alignment, high-throughput, and low cost. Nanonex NIL solutions include all forms of

nanoimprinting, such as thermal plastic, uv-curable, thermal curable, and direct imprinting (embossing). With the most NIL tools sold in the US the last 18 months, and over 100 imprint material orders fulfilled, Nanonex NIL solutions can meet the needs of a broad spectrum of markets, such as optical devices, displays, data storage, biotech, IC, chemical synthesis, and advanced materials. Visit <http://www.nanonex.com> for additional information.